



UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE
United States Patent and Trademark Office
Address: COMMISSIONER OF PATENTS AND TRADEMARKS
Washington, D.C. 20231
www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/467,992	12/20/1999	LEONARD FORBES	303.389US2	3099

21186 7590 04/17/2003

SCHWEGMAN, LUNDBERG, WOESSNER & KLUTH, P.A.
P.O. BOX 2938
MINNEAPOLIS, MN 55402

EXAMINER

LEE, EUGENE

ART UNIT

PAPER NUMBER

2815

DATE MAILED: 04/17/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary

Application No.

09/467,992

Applicant(s)

FORBES ET AL.

Examiner

Eugene Lee

Art Unit

2815

-- Th MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).
- Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 03 February 2003.
- 2a) ☒ This action is **FINAL**. 2b) ☐ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 17-19, 22, 23, 25-27, 29 and 31-51 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 17-19, 22, 23, 25-27, 29 and 31-51 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on _____ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.
- Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
- 11) ☐ The proposed drawing correction filed on _____ is: a) ☐ approved b) ☐ disapproved by the Examiner.
- If approved, corrected drawings are required in reply to this Office action.
- 12) ☐ The oath or declaration is objected to by the Examiner.

Priority under 35 U.S.C. §§ 119 and 120

- 13) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some * c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
2. ☐ Certified copies of the priority documents have been received in Application No. _____.
3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
- * See the attached detailed Office action for a list of the certified copies not received.
- 14) ☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).
- a) ☐ The translation of the foreign language provisional application has been received.
- 15) ☒ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.

Attachment(s)

- 1) ☐ Notice of References Cited (PTO-892)
- 2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948)
- 3) ☒ Information Disclosure Statement(s) (PTO-1449) Paper No(s) _____
- 4) ☐ Interview Summary (PTO-413) Paper No(s). _____
- 5) ☐ Notice of Informal Patent Application (PTO-152)
- 6) ☐ Other:

DETAILED ACTION

Claim Rejections - 35 USC § 103

1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

2. Claims 17 thru 19, 31 thru 33, 37, 38, 41 thru 46, 48, 49, and 51 are rejected under 35 U.S.C. 103(a) as being unpatentable over Pfister 4,761,385 in view of Kanetaki et al. 4,906,590. Pfister discloses (see, for example, FIG. 1) a memory cell comprising a lateral transistor 56, source/drain regions 54, semiconductor material layer (body region) 32, trench capacitor 50, substrate (first plate) 34, capacitor plate (second plate of polycrystalline material) 66, and dielectric layer (insulator layer) 60. A contact from the capacitor plate extends to the source/drain region. The substrate is integral to either source/drain region since the source/drain region is part of the substrate. Pfister does not disclose a first micro-roughened polysilicon surface and a second micro-roughened polysilicon surface. However, Kanetaki discloses (see, for example, FIG. 2) a trench capacitor containing two plurality of hollows (roughened surfaces). In column 1, lines 11- *, Kanetaki states that the plurality of hollows increases the electrode area without increasing the planar area. Therefore, it would have been obvious to one of ordinary skill in the art at the time of invention to include the plurality of hollows (roughened surfaces) in Pfister's invention in order to increase the electrode area without increasing the planar area.
3. Claims 22 thru 25, 34 and 39 are rejected under 35 U.S.C. 103(a) as being unpatentable over Itoh 4,920,389 in view of Kanetaki et al. 4,906,590. Itoh discloses (see, for example, FIG_

Art Unit: 2815

8(k)) a memory cell array structure comprising memory cells wherein an individual memory cell comprises bit lines 222, word lines 234, a low electric resistance region (first source/drain region) 232, high electric resistance semiconductor layer (body region) 204, low electric resistance semiconductor layer (second source/drain region) 202 and a highly electroconductive layer (second plate) 216. In column 13, lines 18-32, Itoh discloses the low electric resistance semiconductor layer 202 serving as a first electrode (first plate) of a capacitor as well as a source region. In column 10, lines 31-41, Itoh discloses the highly electroconductive layer comprising polycrystalline silicon. Itoh does not disclose an etch-roughened surface. However, Kanetaki discloses (see, for example, FIG. 2) a trench capacitor containing two plurality of hollows (roughened surfaces). In column 1, lines 11-*, Kanetaki states that the plurality of hollows increases the electrode area without increasing the planar area. Therefore, it would have been obvious to one of ordinary skill in the art at the time of invention to include the plurality of hollows (roughened surfaces) in Itoh's invention in order to increase the electrode area without increasing the planar area.

4. Claims 26, 27, 29, 35, 36, 40, 47, and 50 are rejected under 35 U.S.C. 103(a) as being unpatentable over Itoh '389 in view of Kanetaki et al. '590 as applied to claims 22-25, 34 and 39 above, and further in view of Wahlstrom 5,396,452. Itoh in view of Kanetaki does not disclose a row decoder and column decoder so as to selectively access the cells of an array. However, Wahlstrom discloses (see, for example, FIG. 2) a dynamic random access memory comprising memory cells arranged in an array wherein word lines (WL) are arranged orthogonal to bit lines (BL). In FIG. 1, Wahlstrom shows a row decoder and a column decoder which access the memory cells according to the row and column addresses applied. It would have been obvious to

one of ordinary skill in the art at the time of invention to have a column and row decoder in order to form a memory cell array wherein the individual memory cells may be accessed easily.

Response to Arguments

5. Applicant's arguments filed 2/03/03 have been fully considered but they are not persuasive.

Regarding the appellants' argument on page 5, middle paragraph that Pfeister does not disclose a transistor having source/drain regions formed "outwardly" from a substrate, the Examiner respectfully disagrees. The limitation in claim 17 states "a transistor formed in a layer of semiconductor material outwardly from a substrate,". Such a limitation is clearly shown in FIG. 1 of Pfeister wherein Pfeister discloses a transistor 56 comprising source/drain regions 54 in a layer of semiconductor material and a gate electrode that is formed outwardly from a substrate 42. Therefore, since the gate electrode is part of the transistor, Pfeister does indeed show "a transistor formed in a layer of semiconductor material outwardly from a substrate,".

Regarding the appellant's argument on page 5, last paragraph that there is no reason for combining Itoh and Kanetaki because Itoh has no mention of an etch-roughened surface and Kanetaki has no mention of a vertical transistor, the Examiner respectfully disagrees. Clearly, Itoh and Kanetaki disclose the same semiconductor art, a trench capacitor. In FIG. 8(k), Itoh shows a capacitor portion comprising regions 202, 210 and 216. In FIG. 2, Kanetaki shows a capacitor portion comprising regions 4, 6, and 1. Therefore, since Itoh and Kanetaki involve the same semiconductor art, it is clearly obvious to one of ordinary skill in the art that Itoh and Kanetaki can be reasonably combined. Regarding appellant's argument that Kanetaki does not

Art Unit: 2815

disclose a vertical transistor, this is not critical to whether a capacitor's electrode can have an etch-roughened surface or whether Itoh and Kanetaki can be combined. What is critical is that Kanetaki clearly states (see column 1, lines 11- *) that a capacitor's electrode area can be increased by roughening its surface and therefore, since Itoh also discloses a capacitor, it would have been obvious to also roughen the surface of Itoh's electrode like Kanetaki in order to increase its area.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Art Unit: 2815

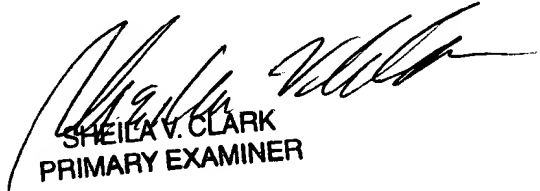
INFORMATION ON HOW TO CONTACT THE USPTO

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Eugene Lee whose telephone number is 703-305-5695. The examiner can normally be reached on M-F 8-5.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie C. Lee can be reached on 703-308-1690. The fax phone numbers for the organization where this application or proceeding is assigned are 703-308-7722 for regular communications and 703-308-7722 for After Final communications.

. Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

Eugene Lee
April 11, 2003


SHEILA V. CLARK
PRIMARY EXAMINER